Fe-408. Be-B05 Owari Laboratory

# **Owari Laboratory**

## [ Design of Three Dimensional Atom Probe(3DAP)] [ Three-dimensional microanalysis using micro-beam and nano-beam SIMS]

Institute of Industrial Science, Department of Material and Environmental Science http://www.owari.esc.u-tokyo.ac.jp/

Research topic 

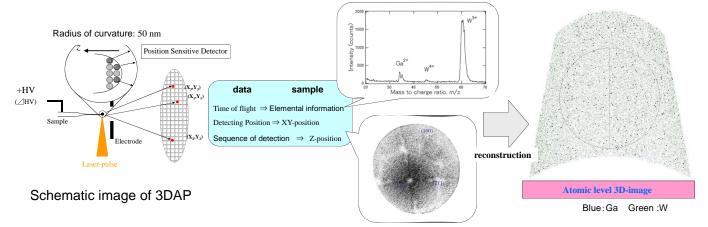
micro and nano material analytical chemistry

Department of Applied Chemistry

### **Design of Three Dimensional Atom Probe(3DAP)**

**Be-B05** 

Atom probe tomography enables the quantitative chemical analysis of nanostructured materials with a nearly atomic scale. By carefully controlled field evaporation, individual atom is removed from a tipshaped sample and their time of flight and detected positions are determined. The atoms are identified by mass spectroscopy and their geometric origin within the specimen is also reconstructed.



### Three-dimensional microanalysis using micro-beam and nano-beam SIMS

Fe-408

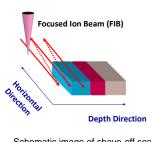
Secondary Ion Mass Spectrometry(SIMS) is analysis method that analyze secondary ions yielded from samples by irradiating accelerated primary ion beam.

#### ◆nano-beam SIMS

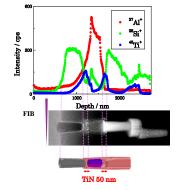
Shave-off depth profile can be acquired directly by the fast horizontal sweep of FIB combined with the very slow vertical sweep.

#### **◆Dual FIB ToF-SIMS**

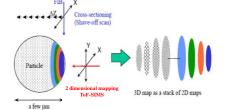
Three-dimensional image can be obtained by operating two FIB alternately. One FIB is for section processing by shave-off scan, the other is for ToF-SIMS mapping.



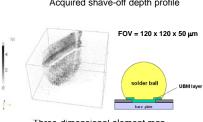
. Schematic image of shave-off scan



Acquired shave-off depth profile



Dual FIB ToF-SIMS basic concept



Three-dimensional element map of UBM layer in solder bump (58Ni+)